



EV 549896578

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. ....09/928,257  
Filing Date .....Aug 10, 2001  
Inventor ..... Guo et al.  
Group Art Unit .....2671  
Examiner ..... Nguyen, K.  
Attorney's Docket No. .... MS1-0952US  
Title: Macrostructure modeling with microstructure reflectance slices

**RULE 312 AMENDMENT**

To: Mail Stop Issue Fee  
Commissioner for Patents  
PO Box 1450

Alexandria VA 22313-1450  
Office of Patent Publication/Publishing Division

From: Mark C. Farrell (Tel. 509-324-9256 ext 243; Fax 509-323-8979)  
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As requested by the Office of Patent Publication/Publishing Division,  
Applicant submits a mere formal correction to a clerical or typographical error in  
the **"Brief Description of the Drawings."** At Applicant's page 6, paragraph  
number [0024], under Brief Description of the Drawings, please amend the single  
letter ("b" to "a") as indicated below:

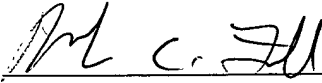
Figures 9a-9c are computer renderings, where Figure 9a is planar view of a  
lumislice, Figure 9b is a sample of three (3) of the lumislice of Figure 9a in  
perspective view, and Figure 9c is sweeping sampling of the lumislice of Figure 9a  
along and about an axis.

This correction does not add new matter or change the scope of the  
specification.

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Date: 8/26/05

Respectfully Submitted,

By:   
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